

**PATENT APPLICATION
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q79703

Hisayuki MIKI, et al.

Appln. No.: 10/586,849

Group Art Unit: 2814

Confirmation No.: 3462

Examiner: Wai Sing LOUIE

Filed: July 20, 2006

For: GALLIUM NITRIDE-BASED COMPOUND SEMICONDUCTOR MULTILAYER
STRUCTURE AND PRODUCTION METHOD THEREOF

PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. § 1.136, Applicants hereby petition for an extension of time of one month, extending the time for responding to the Office Action of April 2, 2008 from July 2, 2008 to August 2, 2008, thus providing for timely filing by Monday, August 4, 2008.

The statutory fee of \$120.00 is being charged to Deposit Account No. 19-4880 via EFS Payment Screen. The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,



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Date: August 1, 2008